

5. A heater device according to claim 1, wherein an electrode for radio frequency power is buried in said ceramic plate.
6. A heater device according to claim 5, wherein said ceramic plate has a thickness of no more than 5 mm.
7. A heater device according to claim 1, wherein said ceramic plate is made of ceramic material essentially consisting of aluminum nitride or magnesia.
8. A heater device according to claim 1, wherein said ceramic plate further comprises an annular low wall surrounding said supporting surface.
9. A film forming device, comprising:  
a process vessel defining a process chamber;  
a heater defining a heating surface and placed in said process chamber; and  
a ceramic plate which is detachably placed on said heating surface of said heater so as to substantially entirely cover said heating surface and defining a surface for supporting an object of a film forming process.
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10. (New) A heater device according to claim 1, wherein said ceramic plate is made of ceramic material essentially consisting of alumina.
11. (New) A film forming device according to claim 9, wherein said heater consists of a ceramic heater.
12. (New) A film forming device according to claim 9, wherein an electrode for radio frequency power is buried in said ceramic heater.
13. (New) A film forming device according to claim 9, wherein said ceramic plate has a thickness of no more than 2 mm.
14. (New) A film forming device according to claim 9, wherein an electrode for radio frequency power is buried in said ceramic plate.
15. (New) A film forming device according to claim 9, wherein said ceramic plate has a thickness of no more than 5 mm.

16. (New) A film forming device according to claim 9, wherein said ceramic plate is made of ceramic material essentially consisting of aluminum nitride or magnesia.

17. (New) A film forming device according to claim 9, wherein said ceramic plate further comprises an annular low wall surrounding said supporting surface.

18. (New) A heater device according to claim 1, wherein said ceramic plate is made of ceramic material essentially consisting of alumina.

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